# Study of the Properties of Quantum Dot InAs/GaAs Scintillator for Future 4D Trackers

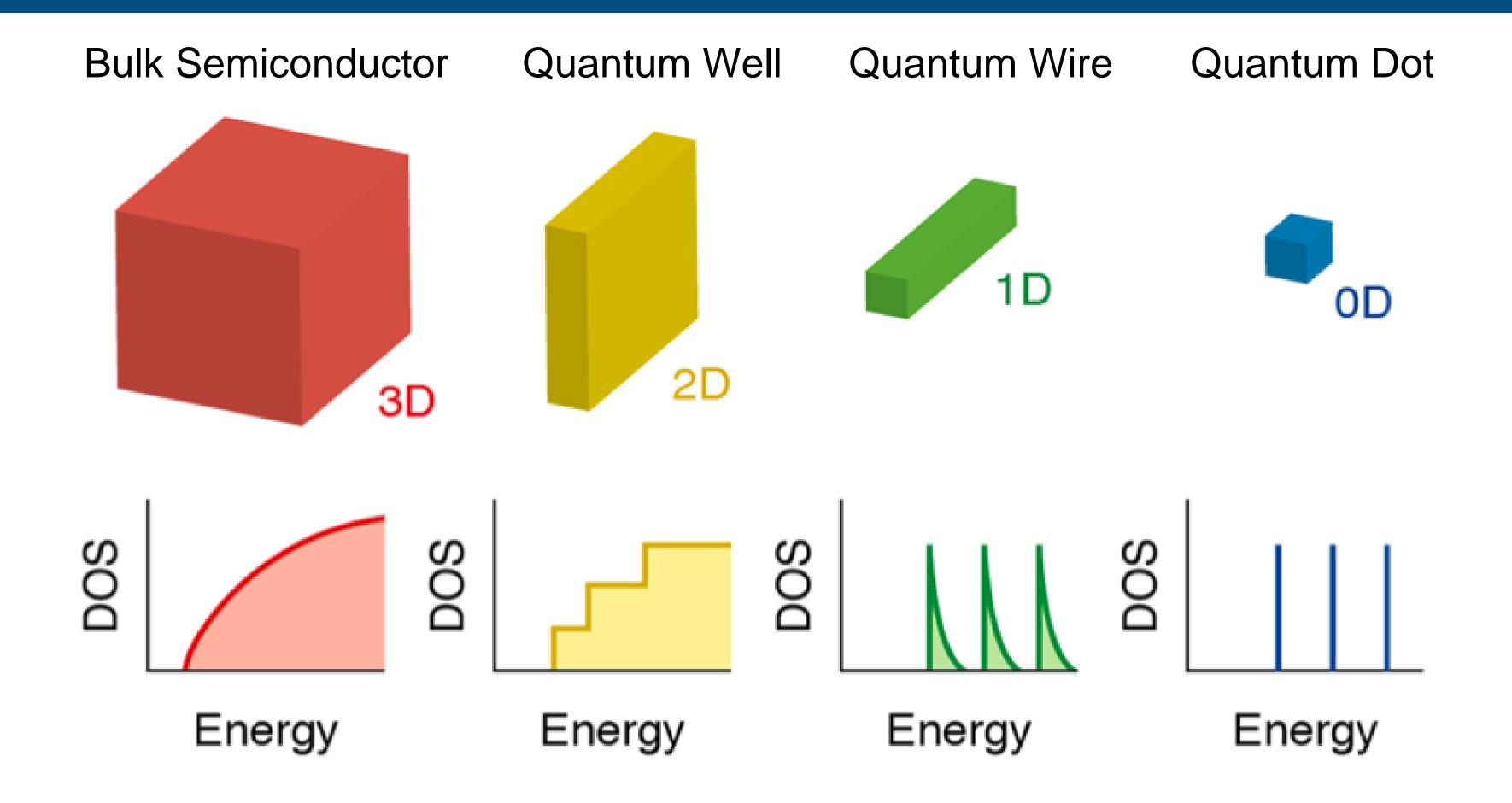
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#### Need for Nanomaterial Based Scintillator

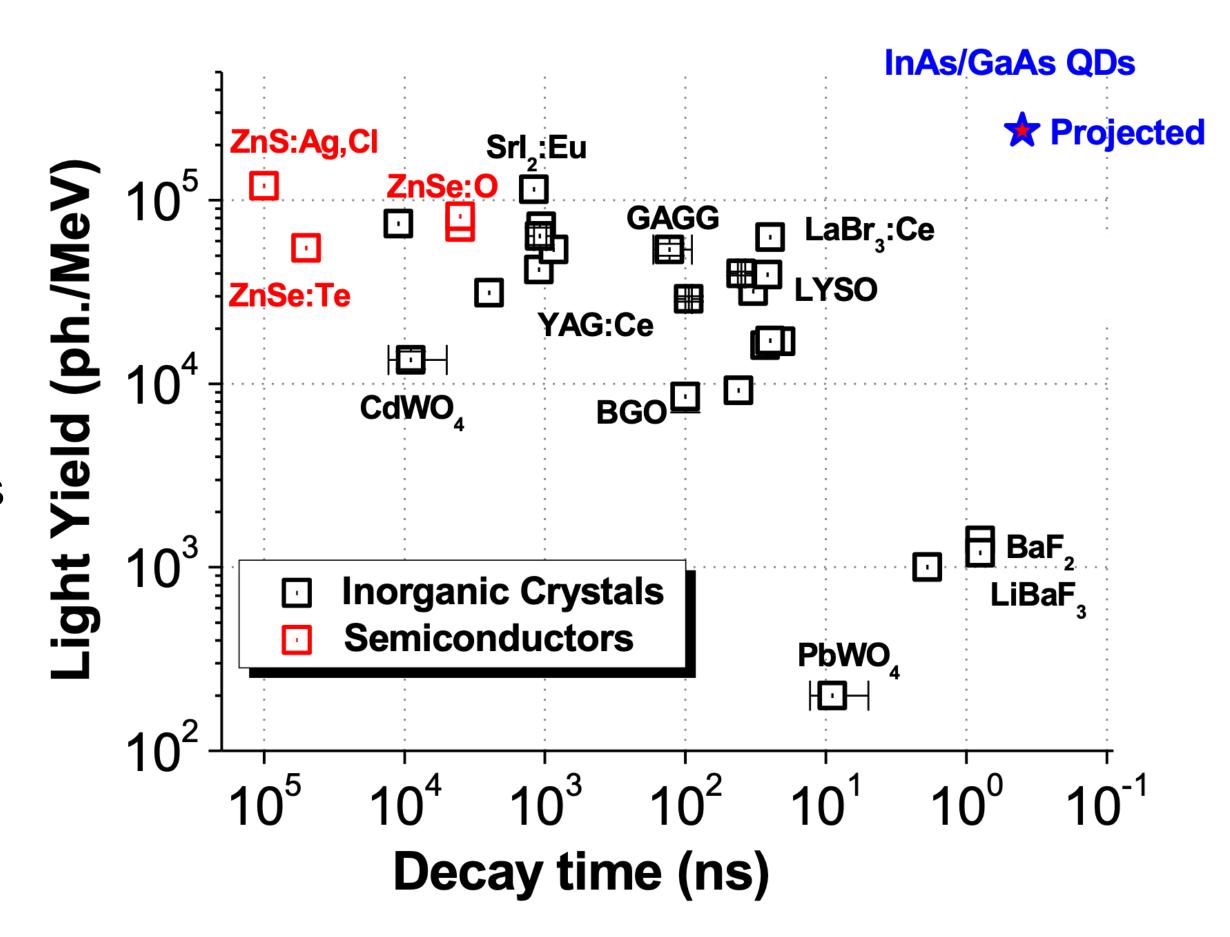


- As particle size decreases, they show different properties from the bulk
- Discreet energy in 0D material Quantum Dots (~ few nm size)
- Quantum confinement occurs in all three directions

### InAs Quantum Dots - Novel Scintillator

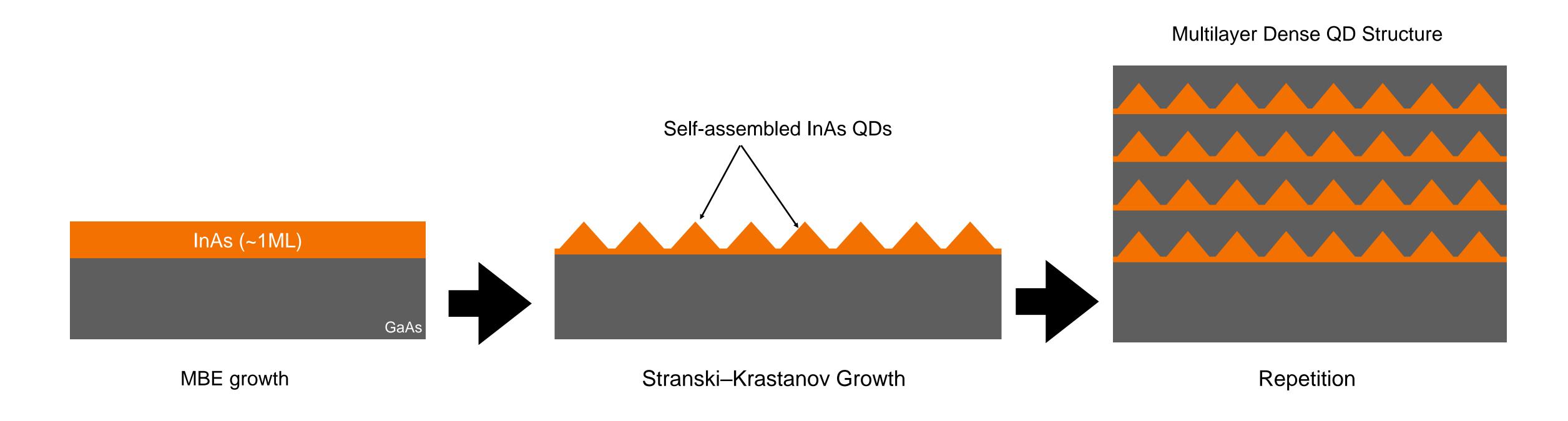
InAs QDs in GaAs - very high expectations

- Direct Gap very high light yield (~240,000 photons/MeV)
- High electron mobility (up to 8500 cm<sup>2</sup>/V)
- Fast transport and capture of electrons in QDs ~ 2-5 ps
- Very short emission time ~ < 1ns allows faster sampling rate
- Relatively high Z radiation hard

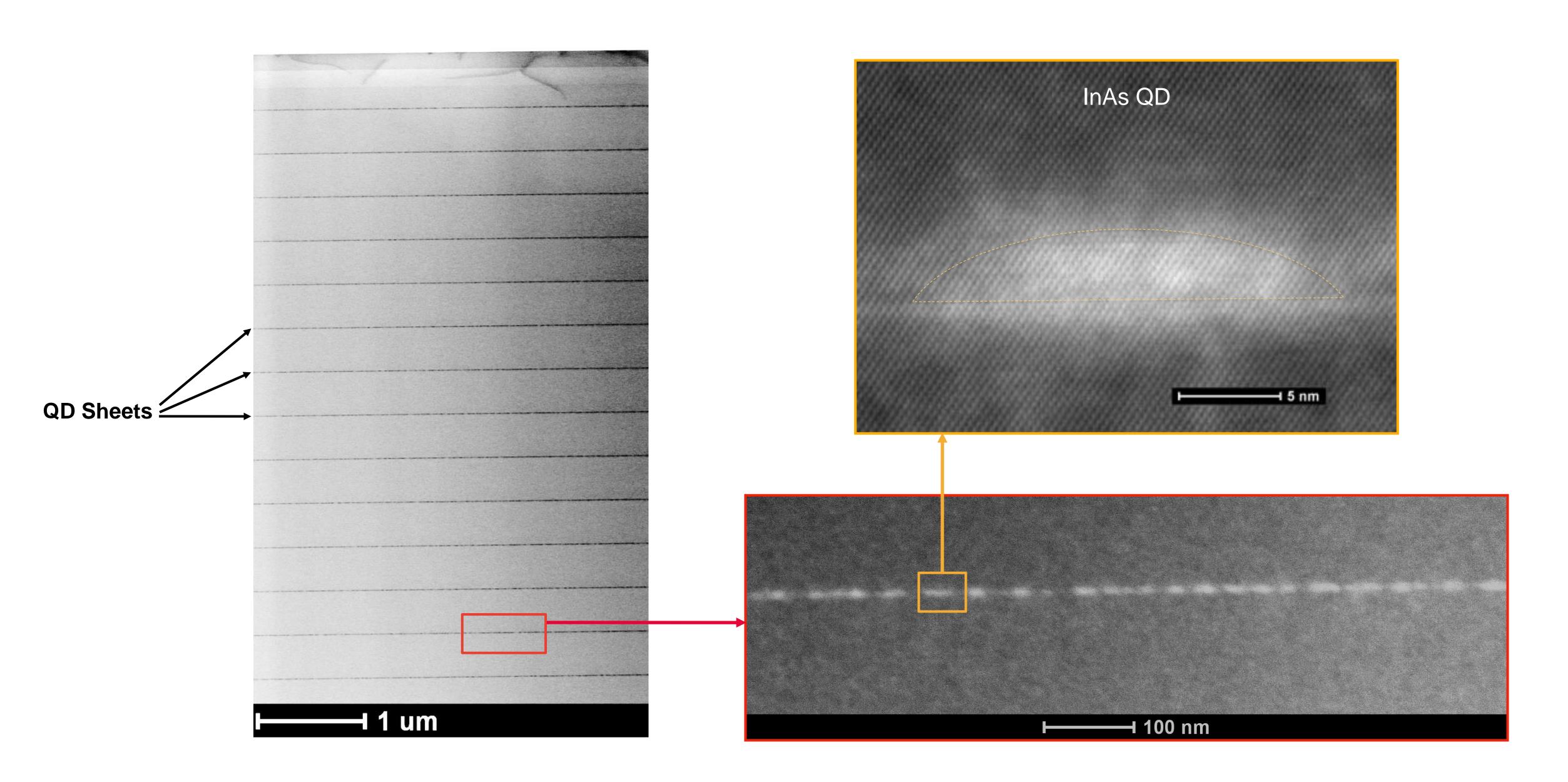


### Growth of InAs QDs in GaAs Matrix

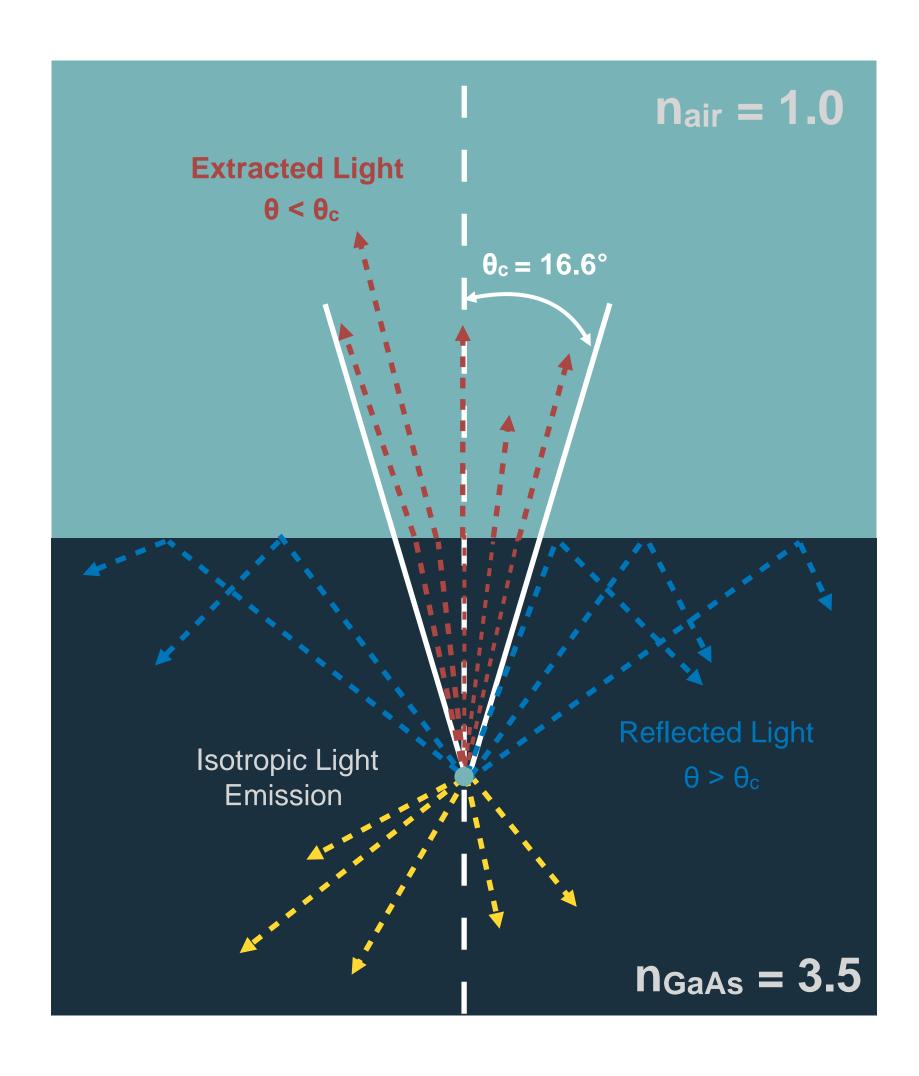
- Grown using Molecular Beam Epitaxy at ultra high vacuum.
- Minimization of the strain energy leads to stable nm-scale stable InAs islands QDs.
- QDs are capped with ~ 2MLs of AlAs.
- Multilayer structure is grown by repetition.



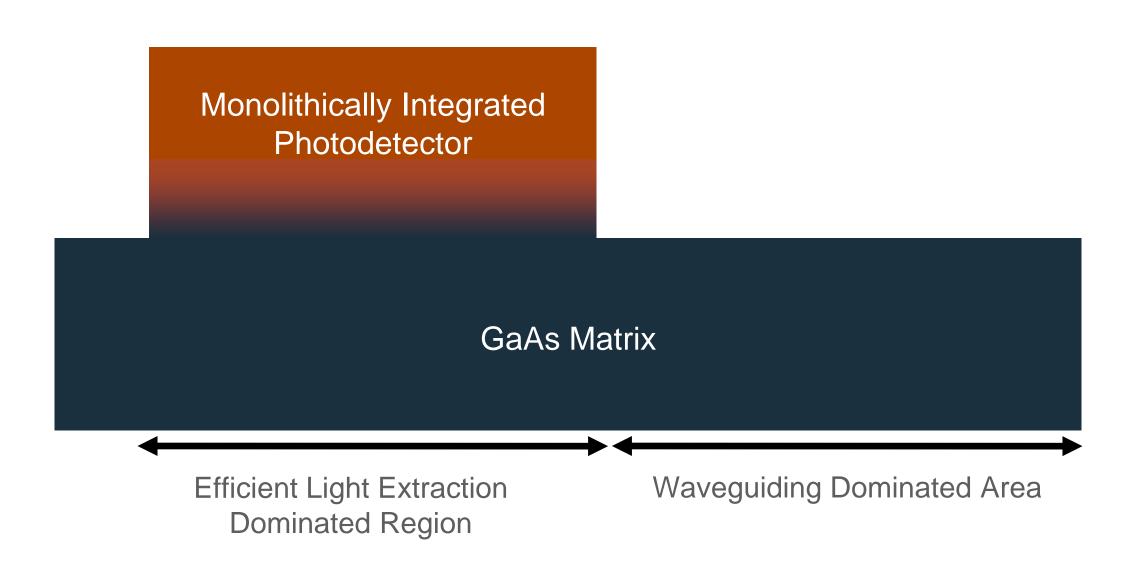
## InAs/GaAs Images



## Efficient Collection of light from high refractive index material



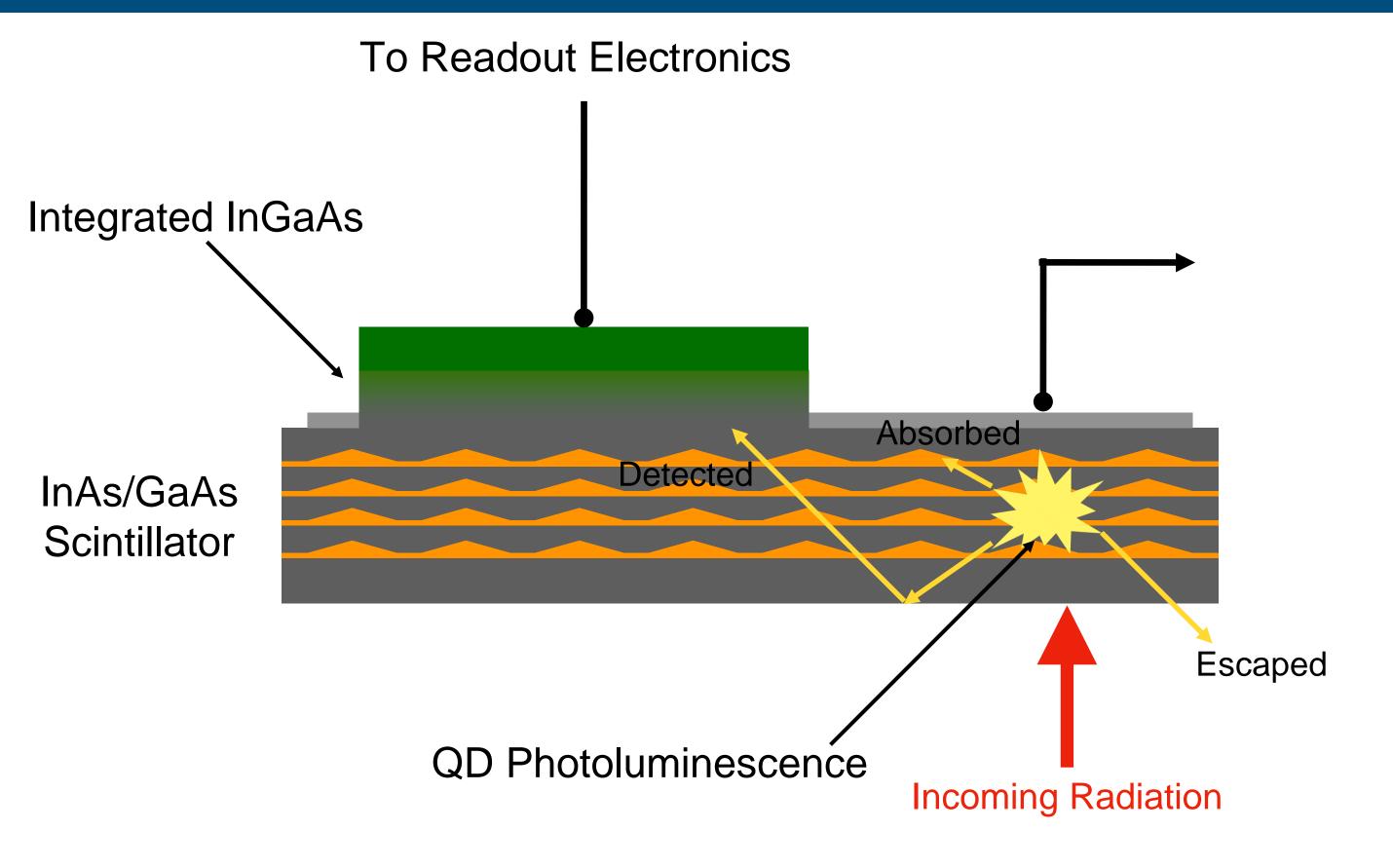
LEE<sub>GaAs/Air</sub>=
$$\frac{1}{2n^2}$$
 ~2% per side



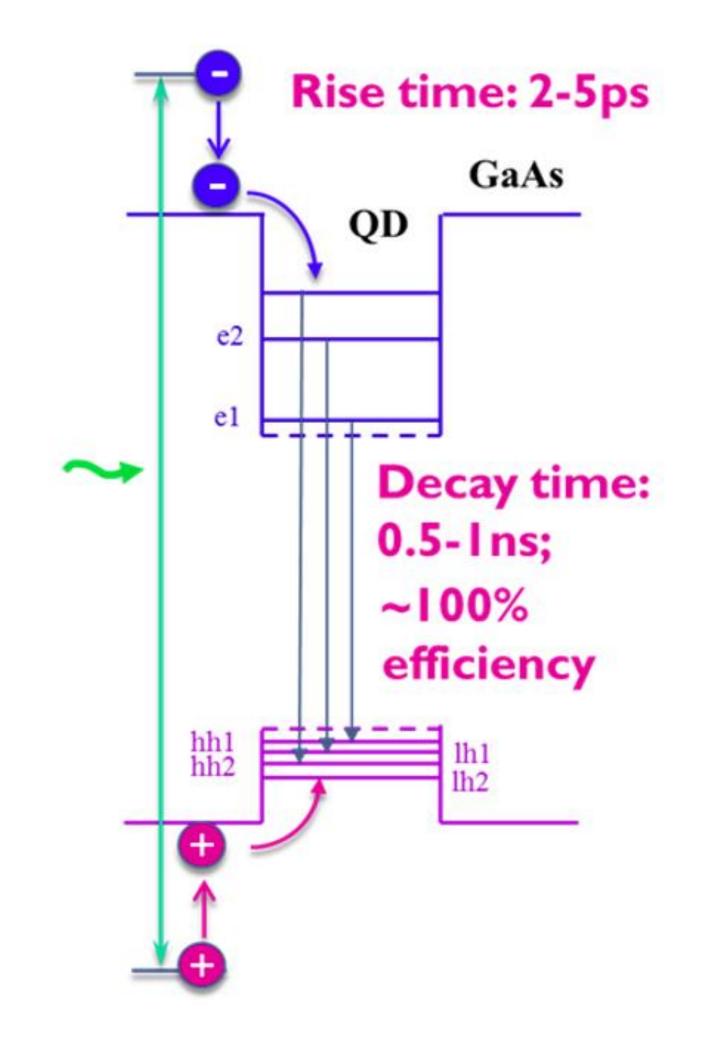
#### Why Monolithic Integration?

- More efficient light collection
- High refractive index medium can be used as waveguide
- Ability to design photodetector specifically tuned to QD's photoluminescence spectra

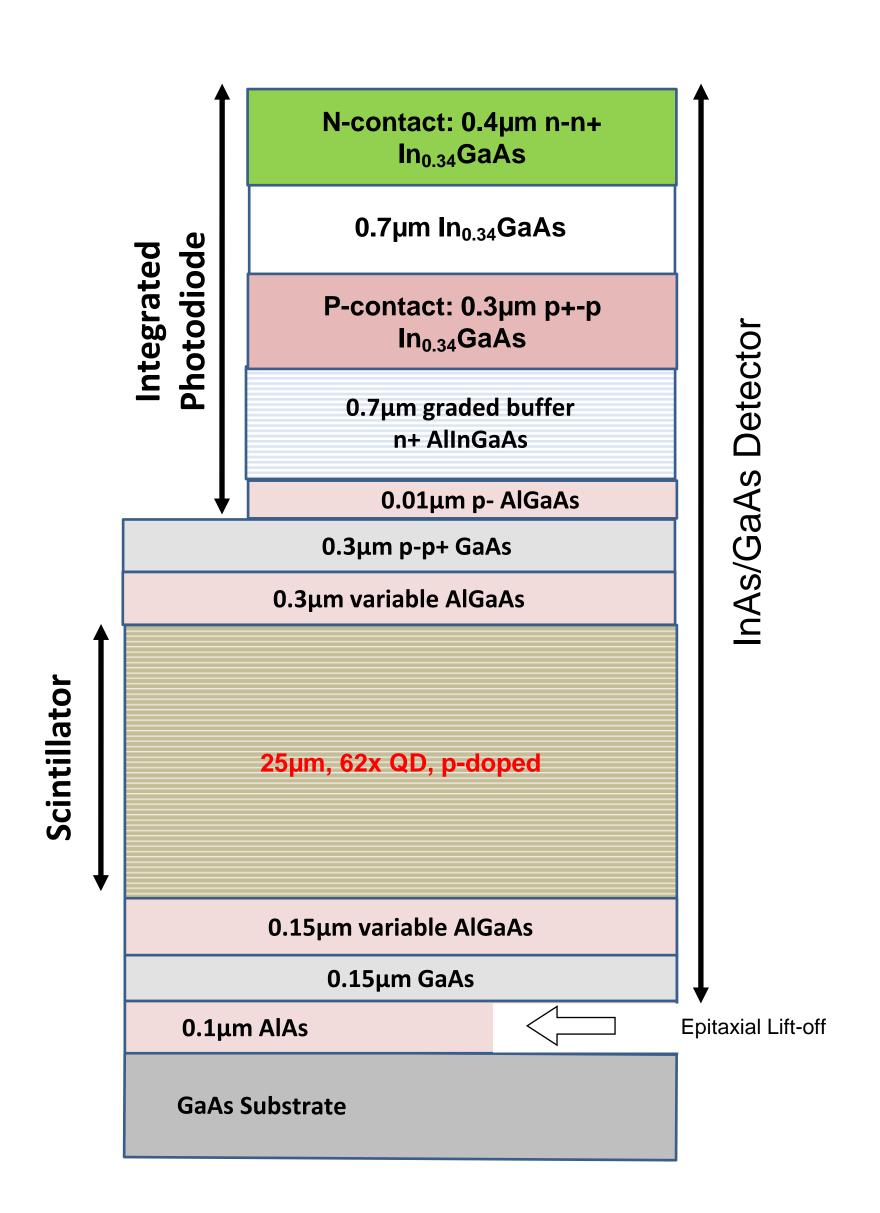
## Working Principle of Novel InAs/GaAs Based Detector



- Ionizing particle produces e-/h pairs in GaAs
- Charges quickly captures by QDs (~few ps)
- $^{ullet}$  Excited state QDs emit 1.1 eV photons with emission time of  $\sim$  1 ns
- Monolithically integrated InGaAs photodetector captures photons



#### InAs/GaAs with Monolithic InGaAs Detector



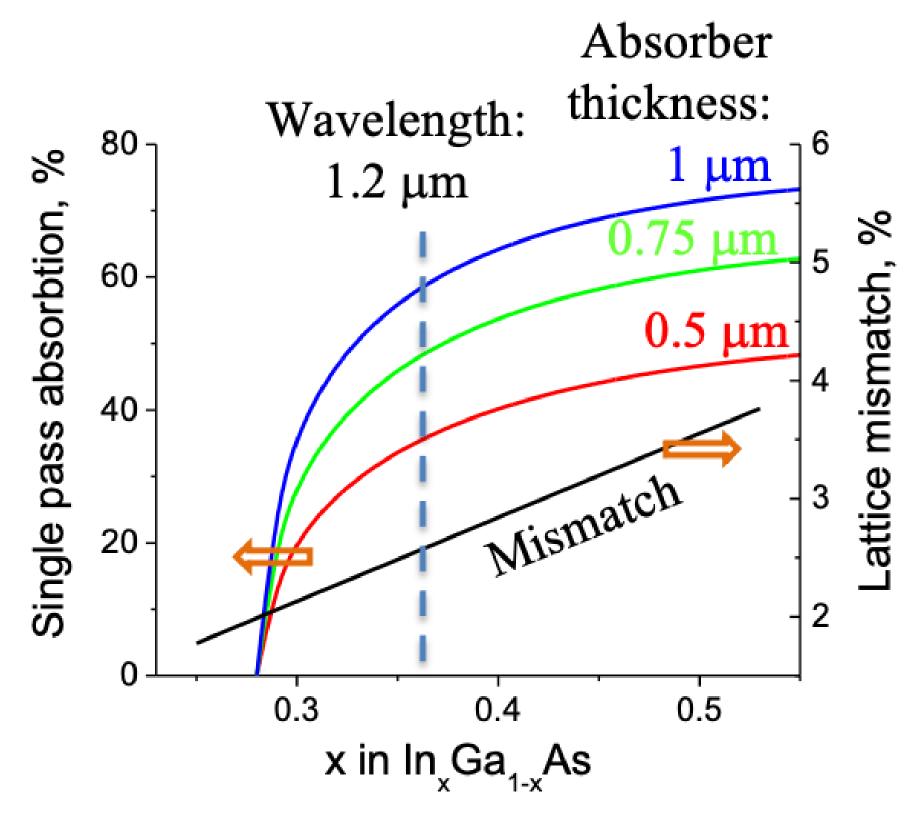
#### The detector consists of three integrated systems:

- QD/semiconductor as a radiation stopping material
- Waveguide for QD emission
- Photodiode for optoelectronic conversion

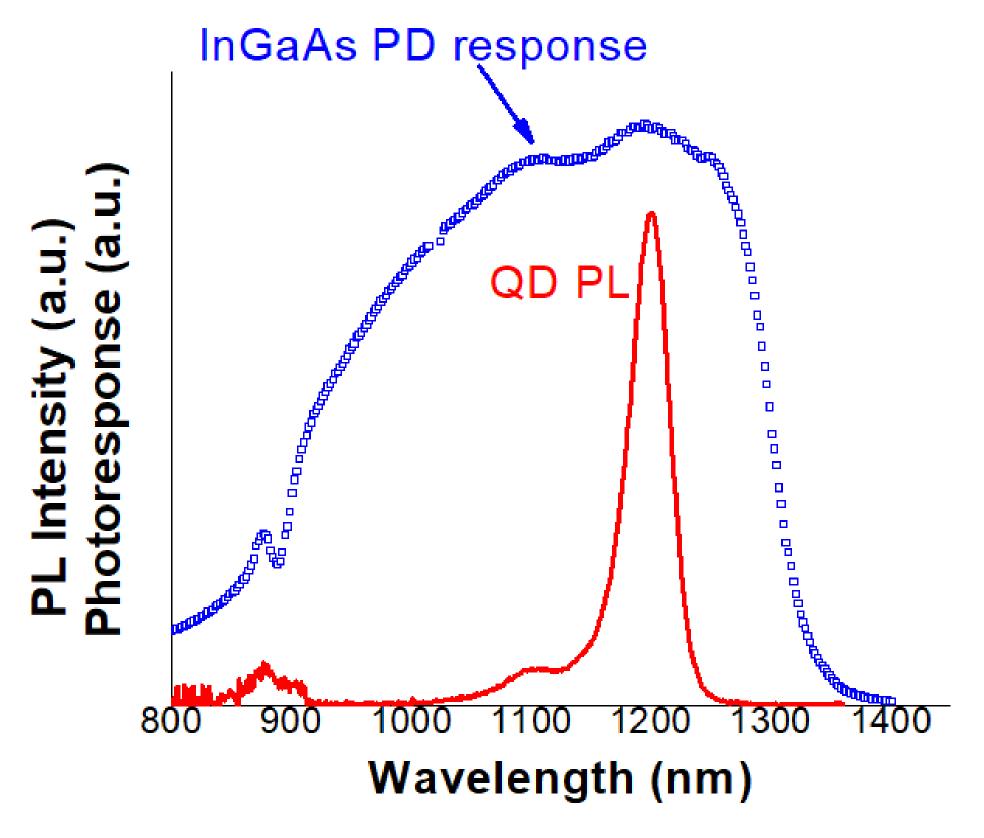
#### InAs/GaAs with Integrated Photodetector:

- Complete detector is grown in single Molecular Beam Epitaxy process
- Detector Mesa and contact metallization is formed with two mask lithography
- ~25 µm thick detector is released from the GaAs substrate by epitaxial lift-off

## Design of Monolithically Integrated InGaAs Photodetector



Single pass absorption of 1.2  $\mu m$  light with variable composition of In with associated strain on GaAs substrate

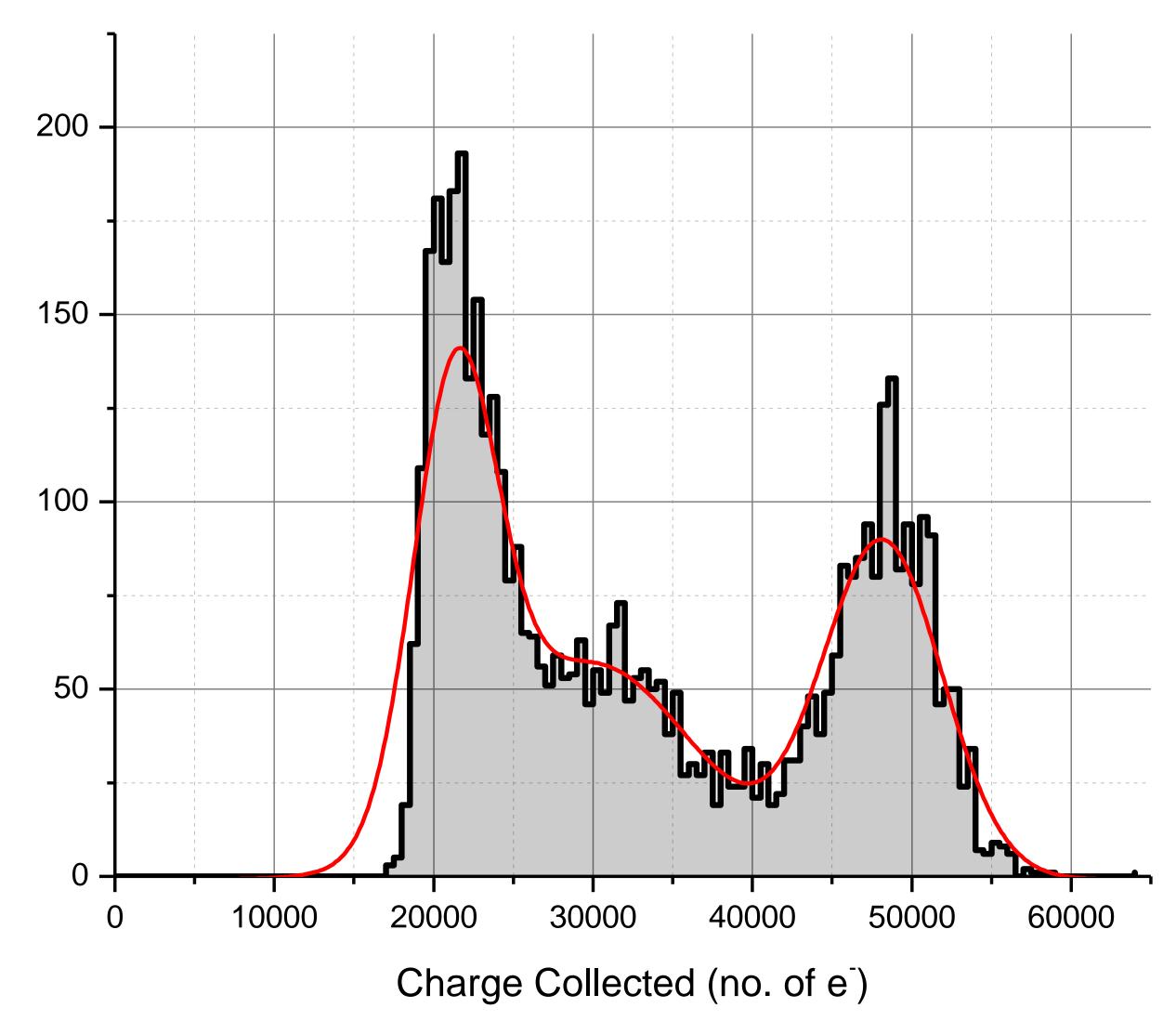


InAs QD photoluminescence and InGaAs photodetector photosensitivity

- QD luminescence at 1.2 μm wavelength detects use of photodetector (PD) with bandgap less than 1eV.
- InGaAs with In-content more than 34% provide practical PD efficiency.
- Metamorphic layer is needed to compensate lattice mismatch.

## Measurement with 5.5 MeV Alpha Particle

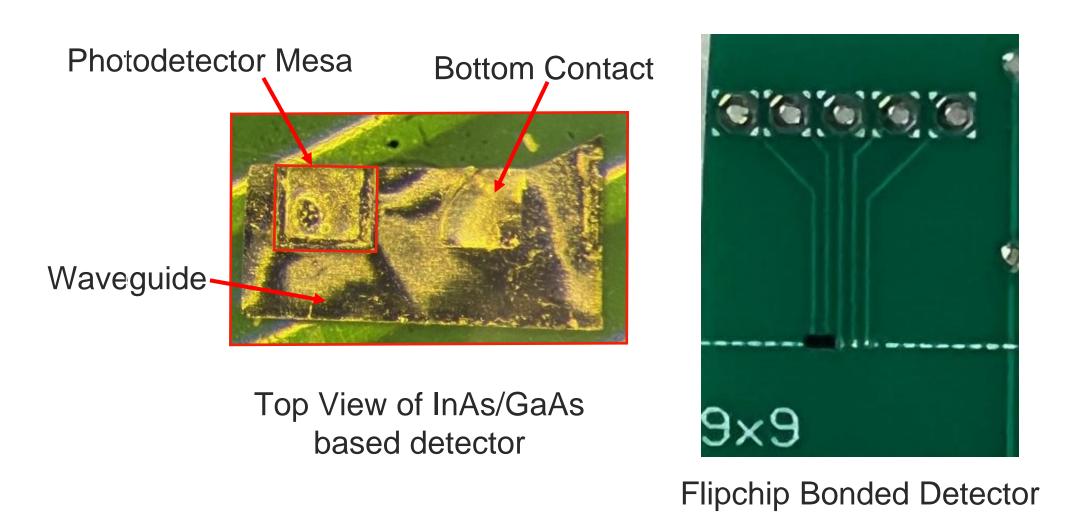
#### Histogram of 4.5 MeV Alpha particles



Number of Events

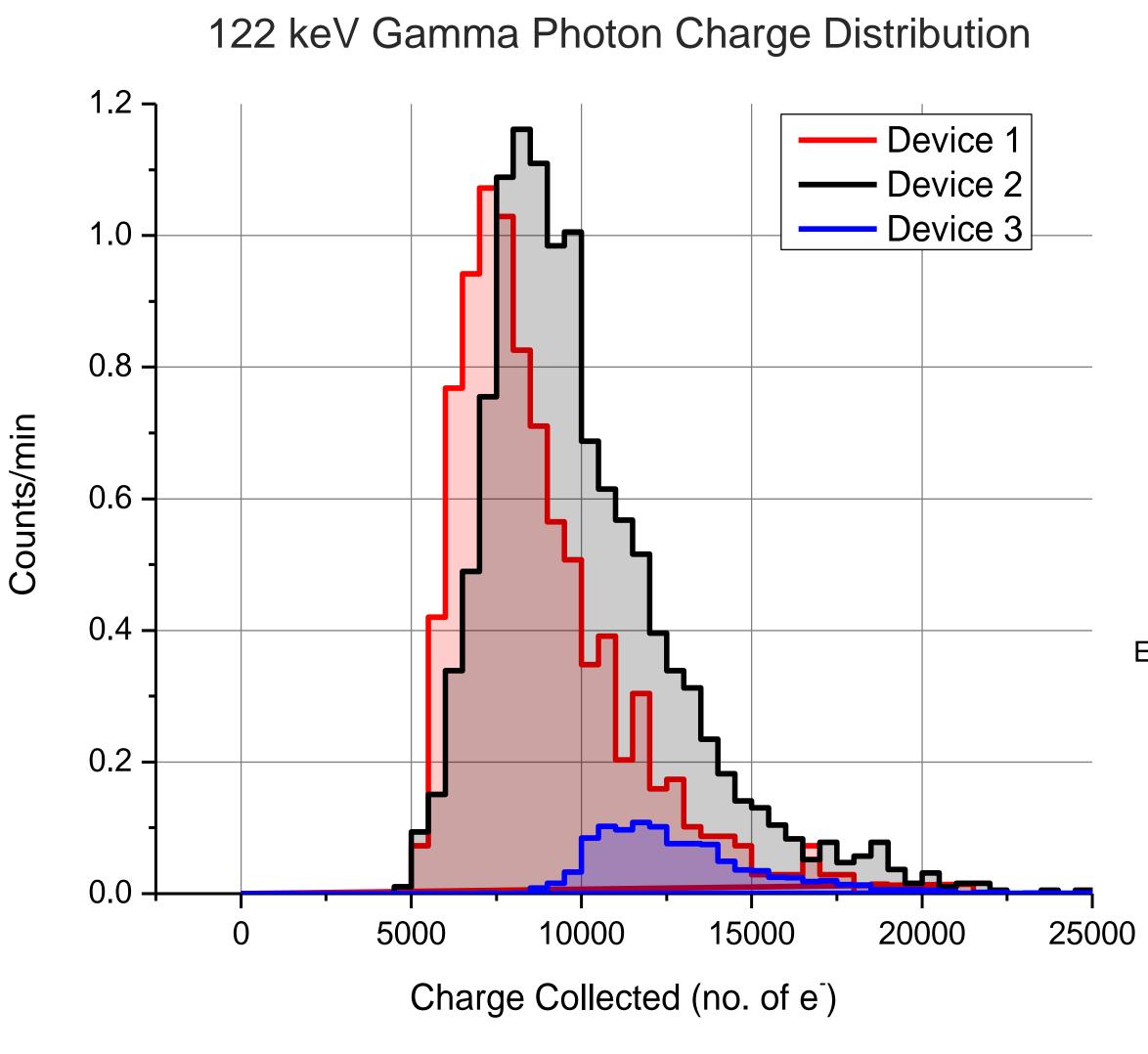
The presented data is collected with charge sensitive preamplifier followed by shaping amplifier

# The Detector is bonded to PBC using flip chip method for easy readout



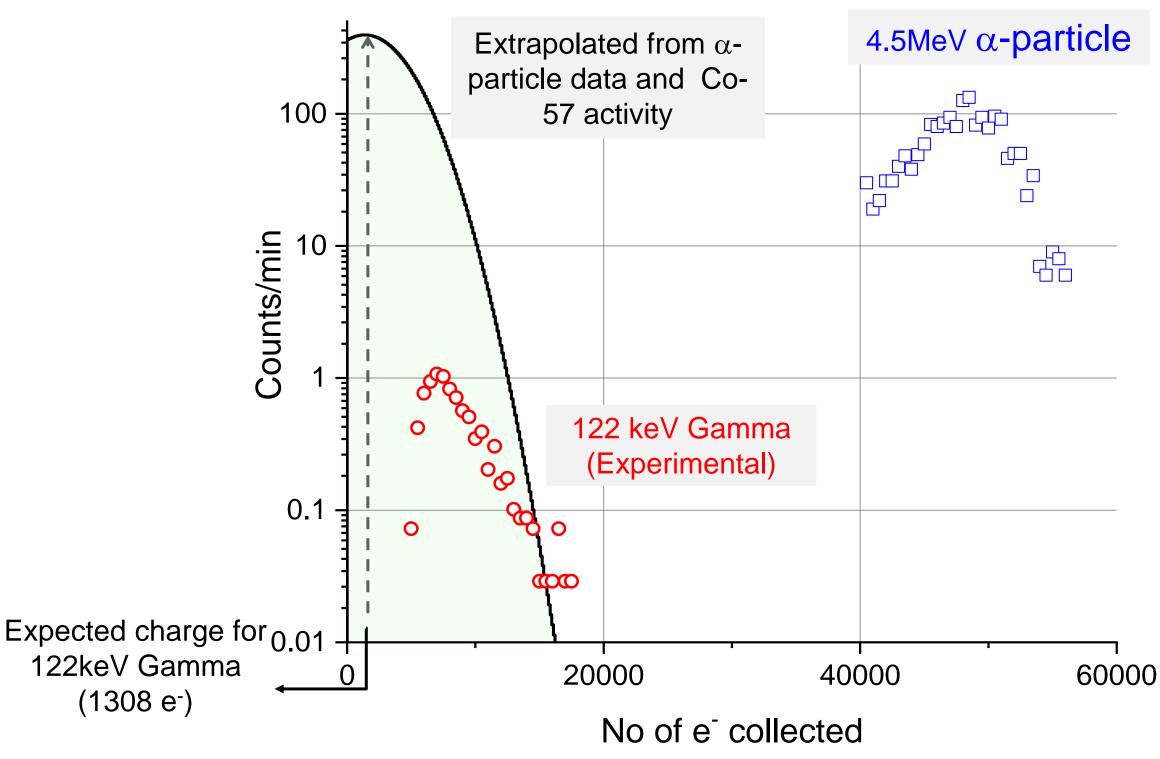
- Bimodal charge distribution is observed
- Low charge peak corresponds to the alpha particle event in waveguiding region
- High charge peak corresponds to alpha particle events underneath the photodetector
- ~10,000 ph.e /MeV charge collected
- Lower charge threshold is still noise limited

#### Measurement with Gamma Photons from Co-57



The presented data is collected with charge sensitive preamplifier followed by shaping amplifier



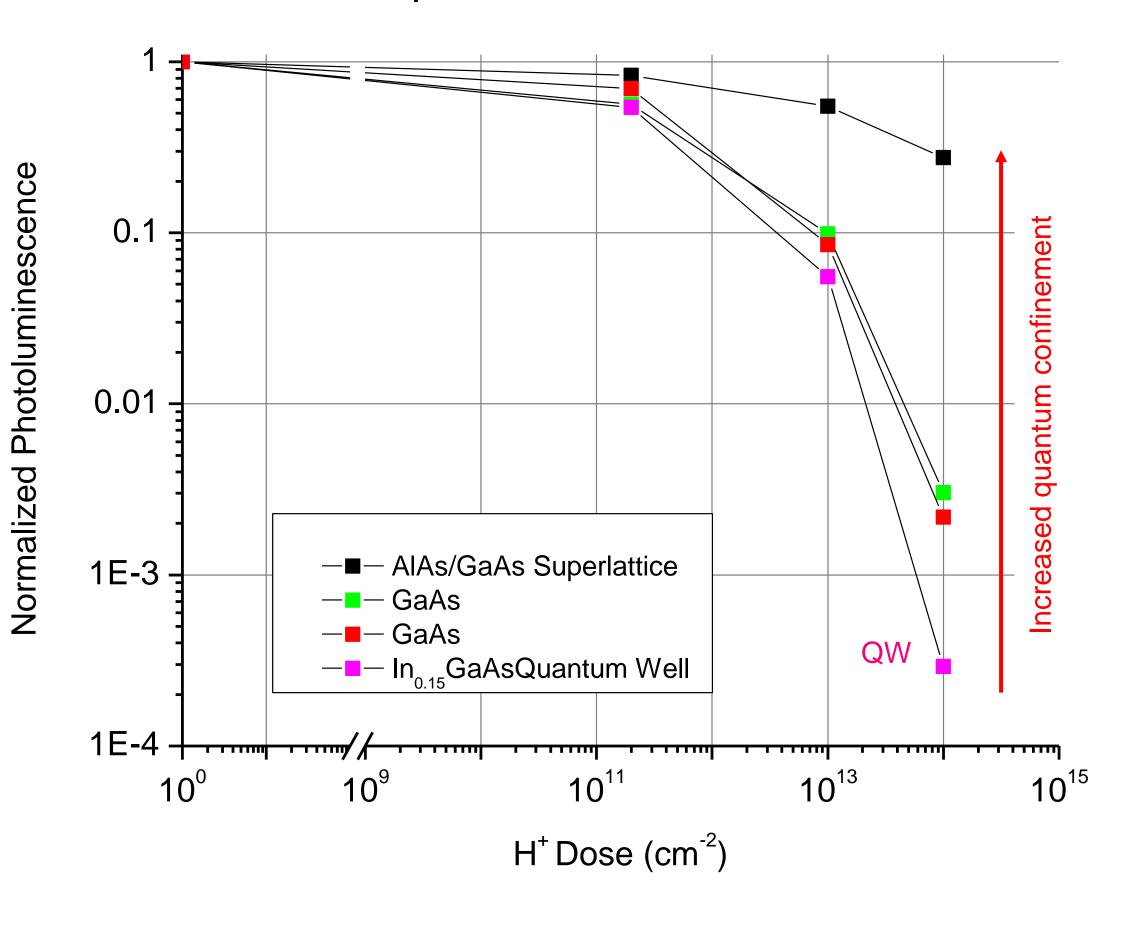


- The gamma responses are noise/threshold limited
- Majority interactions are screened by the noise level
- Tail of collected charge distribution is observed
- Charge collection is greater than 80,000 ph. e/MeV
- Possibility of Birk's suppression need to study for this novel material

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## Engineering of Radiation Hard InAs Quantum Dots

Effect of 1 MeV Proton Irradiation on Quantum dots photoluminescence



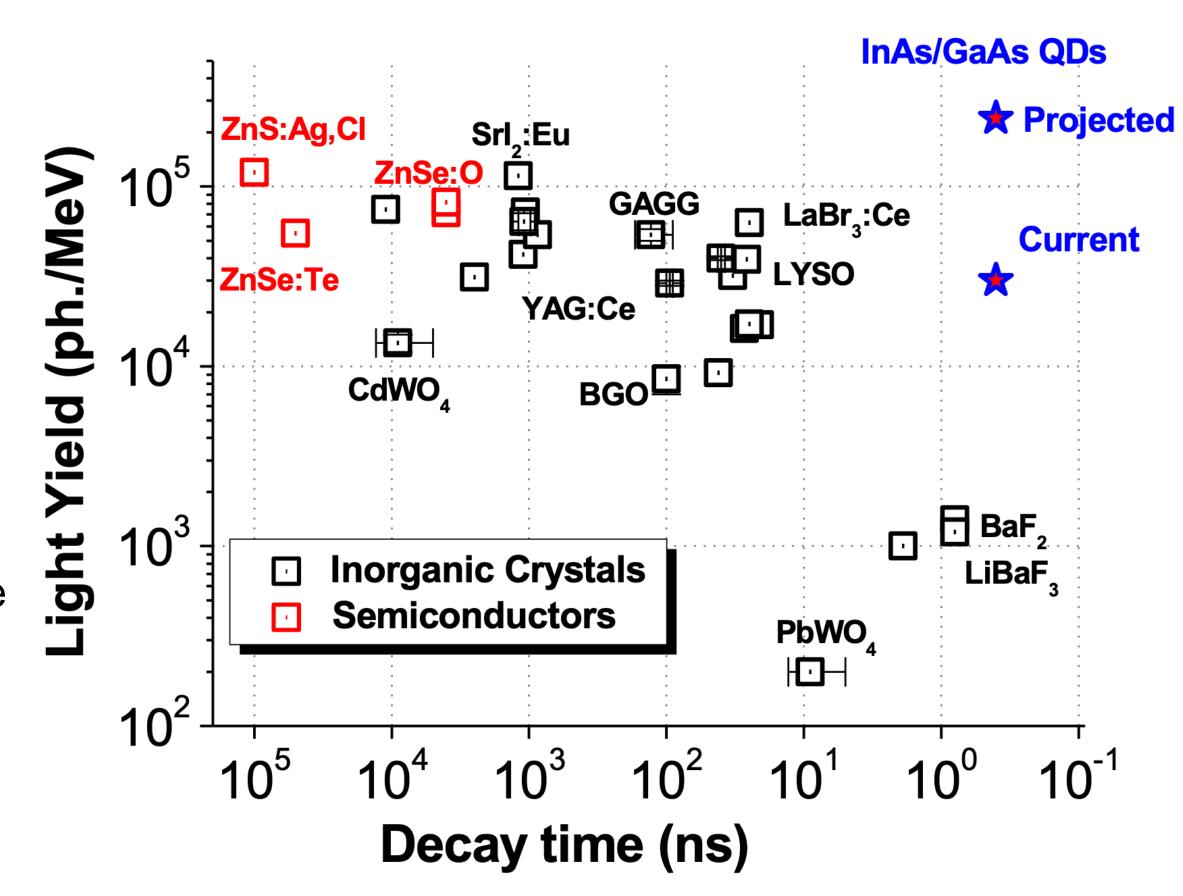
- Proton generates displacement defects along its path
- Degradation of the PL due to non-radiative recombination on these defects
- The highest radiation hardness is observed in QDs embedded in AlAs/GaAs superlattice structure, corresponding to Al<sub>0.2</sub>Ga<sub>0.8</sub>As alloy
  - Highly localized states of carriers in QDs
  - Lower probability for carriers to escape the QDs and recombine non-radiatively

InAs Quantum dots can be designed to be a radiation hard by hosting it in high barrier periodic structures

## Summary

Demonstrated a novel semiconductor-based scintillator for charged particle detection

- Low self absorption (< 1 cm<sup>-1</sup>)
- Very short scintillation time (< 1ns)</p>
- Suitable for room temperature
- Can be operated without bias
- Designed and integrated monolithic photodetector
- Can be designed to be radiation hard
  - QDs hosted in high barrier like AlAs/GaAs superlattice
- High charge collected
  - 10,000 ph.e/MeV in case of Alpha particles
- charge >80,000 ph.e/MeV is observed for gamma photons



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